Application No.: 09/541,426 Docket No.: 8733.230.00

Amendment dated April 6, 2009

Response to Office Action dated January 7, 2009

AMENDMENTS TO THE DRAWINGS

The attached sheet(s) of drawings includes changes to Fig 3. This sheet, which includes

Fig. 3, replaces the original sheet including Fig. 3. The changes to Fig. 3 include an electric field

inducing window formed in hole or slit in the passivation layer and the gate insulating layer.

Attachment:

Replacement Sheets

Annotated Sheets showing changes

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DC:50614896.1

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REMARKS

At the outset, the Examiner is thanked for the thorough review and consideration of the pending application. The Office Action dated January 7, 2009 has been received and its contents carefully reviewed.

By this Amendment, claim 1 has been amended, and FIG. 3 has been amended. No new matter has been added. Claims 1, 3, 20-25, 27, 28 and 57 are currently pending. Reexamination and reconsideration of the pending claims is respectfully requested.

In the Office Action, the drawings are objected to under 37 CFR 1.83(a). With respect to the objection to the drawings, FIG. 3 has been amended in response to the Examiner's objection. The objection of drawings is respectfully traversed and reconsideration is requested. The amended FIG. 3 shows every feature of the invention specified in claim 1.

In the Office Action, claims 1, 3, 20-25, 27-28 and 57 are rejected under 35 U.S.C. § 112, first paragraph, as failing to comply with the written description requirement.

Claim 1 recites a limitation of "the electric field inducing window formed in a hole or slit in at least one of the passivation layer and the gate insulating layer" that is disclosed the

At this time, the electric field inducing window 51 is formed by patterning a hole or slit in the passivation layer 37 or pixel electrode 13 in order to obtain an electric field distortion effect. Also, the electric field inducing window 51 may be formed by patterning partially or entirely the gate insulator 35.

following at page 9, lines 3-8:

Accordingly, Applicants respectfully request that the rejection to the claims be withdrawn.

Applicants believe the application is in condition for allowance and early, favorable action is respectfully solicited.

If for any reason the Examiner finds the application other than in condition for allowance, the Examiner is requested to call the undersigned attorney at (202) 496-7500 to discuss the steps

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necessary for placing the application in condition for allowance. All correspondence should continue to be sent to the below-listed address.

If these papers are not considered timely filed by the Patent and Trademark Office, then a petition is hereby made under 37 C.F.R. §1.136, and any additional fees required under 37 C.F.R. §1.136 for any necessary extension of time, or any other fees required to complete the filing of this response, may be charged to Deposit Account No. 50-0911. Please credit any overpayment to deposit Account No. 50-0911.

Dated: April 6, 2009

Respectfully submitted,

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Docket No.: 8733.230.00

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